Formation and Energy Band Engineering of Ternary Alloy Ge_{1-x-y}Sn_xC_y Layers

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Abstract

We have investigated the crystalline and optical properties of epitaxial layers of ternary alloy $Ge_{1-x-y}Sn_xC_y$ grown on Si. We achieved the formation of strain relaxed $Ge_{1-x-y}Sn_xC_y$ epitaxial layers with a C content as high as 2%. XPS and Raman spectroscopy measurements revealed that C atoms preferentially bond with Sn atoms, which enhances the incorporation of C atoms into substitutional sites in Ge. We also demonstrate the control of the energy bandgap of $Ge_{1-x-y}Sn_xC_y$ layers with the Sn content.

1. Introduction

 $Ge_{1-x-y}Sn_xC_y$ ternary alloy is one of attractive materials for electronic, optoelectronic, and photovoltaic applications. $Ge_{1-v}C_v$ and $Ge_{1-x}Sn_x$ with a high C or Sn content over a several % promise to be a direct bandgap semiconductor with group-IV elements [1,2]. In addition, $Ge_{1-x-y}Sn_xC_y$ ternary alloy is expected to realize independent control of the energy band structure and lattice constant with controlling each element content. However, the thermoequilibrium solubility of Sn and C in Ge is very low, below 1% [3,4]. Especially, the substitutional C content in a $Ge_{1-y}C_y$ epitaxial layer grown on Si substrate is reported as low as 2.6% even with a flux C content of 7% [5]. On the other hand, the binding energy of Sn-C bond and Sn-vacancy is expected to be stable in Ge matrix by theoretical calculation [6]. Hence, simultaneous incorporation of Sn and C atoms is expected to raise the substitutional C content. In fact, we recently reported that the substitutional C content can be raised by the formation of $Ge_{1-x-y}Sn_xC_y$ ternary alloy layer grown on Ge substrate [7]. However, the relationship between Sn and C in Ge matrix and the optical property of $Ge_{1-x-y}Sn_xC_y$ layers have not been understood in detail yet. In this study, we prepared Ge1-x- $_{y}$ Sn_xC_y epitaxial layers on Si substrate and investigated the crystalline and optical properties of $Ge_{1-x-y}Sn_xC_y$ layers.

2. Sample preparation

After chemically and thermally cleaning Si (001) substrate, a Ge_{1-x-y}Sn_xC_y layer was grown on Si by using a radio frequency (RF) sputtering system. The substrate temperature was 290°C, and the thickness was 200 nm. The content of Sn was ranging from 0% to 8% by controlling the sputtering rate, while the C content was fixed at 2%. The surface cleaning of Si substrate and the epitaxial growth of Ge_{1-x-y}Sn_xC_y layer was confirmed with reflective high-energy electron diffraction (RHEED).

3. Results and discussion

Figure 1(a) shows a typical result of X-ray diffraction two dimensional reciprocal space mapping (XRD-2DRSM) around the $\overline{224}$ reciprocal lattice point for the Ge_{1-x-} _ySn_xC_y/Si sample with a Sn content of 3.6%. Figure 1 (b) shows the summary of the diffraction peak positions of $Ge_{1-x-y}Sn_xC_y$ layers estimated with XRD-2DRSM. We can see that the strain in all $Ge_{1-x-y}Sn_xC_y$ layers on Si is fully relaxed. Also, the lattice constant of $Ge_{1-x-y}Sn_xC_y$ layer can be controlled with the Sn content.

We investigated the chemical bonding state of C in Ge₁. *x-y*Sn_xC_y layers with X-ray photoelectron spectroscopy (XPS). Figures 2(a) and 2(b) show photoelectron spectrum of the C1s bonding state for Ge_{0.98}C_{0.02} (without Sn) and Ge0.90Sn0.08C0.02 layers, respectively. The C1s spectrum was deconvoluted assuming two kinds of the chemical bonding states related to C-C at 285 eV and C-Ge or C-Sn at 283 eV. We consider that the C-C bond should be related to interstitial or precipitated C atoms. Hence, the substitutional C content in Ge was estimated from the area intensity of the bonding state related C-Ge or C-Sn bond. Figure 3 shows the area intensity of the peaks related to C-C and C-Sn/C-Ge bonds as a function of the Sn content. The area intensity related to the C-C bond obviously decreases with incorporation of Sn, while the total C content is a little fluctuated due to the variability of the deposition condition. The intensity ratio of the bonding state related to C-Ge or C-Sn to the total bonding state is higher than 90% in $Ge_{1-x-y}Sn_xC_y$ with a Sn content of 8.1%.

Figures 4 (a) and 4(b) show Raman scattering spectra related to Ge-Ge and Ge-C bonds, respectively, for the Ge_{1-x-} $_ySn_xC_y/Si$ samples. The peak related to Ge-Ge bond shifts to a smaller wavenumber with increasing in the substitutional Sn content. On the other hand, the peak related to Ge-C bond is clearly observed around 550 cm⁻¹ only for the Ge_{1-y}C_y/Si sample without Sn. Results of XPS and Raman scattering measurements indicate that C atoms in Ge_{1-x-y}Sn_xC_y layer preferentially bonds with Sn atoms, that can be attributed to the compensation of the local strain around Sn and C in Ge matrix.

Figure 5 shows the Tauc plot for indirect transition from the absorption spectrum of $Ge_{1-x-y}Sn_xC_y/Si$ samples measured with Fourier transform infrared spectroscopy (FTIR). The energy bandgap can be estimated by the following Tauc equation [8],

$$(\alpha h \upsilon)^{1/n} = (h \upsilon - E_{\rho}) \tag{1}$$

where α is the absorption coefficient, ν is the frequency of incident photon, and E_g is the energy bandgap of $Ge_{1-x-y}Sn_xC_y$ layer. Here, the *n* value was estimated to be about 2 for all samples, meaning that the indirect transition is dominant. Figure 6 shows the Sn content dependence of the energy bandgap of $Ge_{1-x-y}Sn_xC_y$ layers. Theoretically predicted energy bandgap of $Ge_{1-x}Sn_x$ without C is also shown for reference [2]. The energy bandgap of ternary alloy $Ge_{1-x-y}Sn_xC_y$ layers can be controlled from 0.60 eV to 0.55 eV with increasing in the Sn content of 0–8%.

4. Conclusions

We investigated the crystalline and optical properties of strain relaxed $Ge_{1-x-y}Sn_xC_y$ layers on Si substrate with a C content as high as 2%. The Sn incorporation improves on the introduction of C into substitutional sites in Ge matrix with the formation of Sn-C bond, which would compensate the local strain. We demonstrated the energy band engineering of $Ge_{1-x-y}Sn_xC_y$ layer with controlling Sn and C contents.

Acknowledgements

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(a) (b) 7. Reciprocal lattice constant Q_v (nm⁻¹) (nm⁻¹) Sn 0% Si (224) Si (224) Sn 3.6% 7.3 7.3 Reciprocal lattice constant Qv 11 Strain relaxe Sn 8.1% 7.2 7.2 GeSnC (224) 7.1 7.1 Psuedomorphic 7 7 6.9 6.9 6.8 6.8 -5.15 -5.1 -5.05 -4.95 -4.9 -4.95 -4 9 -52 -5 -5.05 Reciprocal lattice constant Q_x (nm⁻¹) Reciprocal lattice constant Q_x (nm⁻¹)

Fig. 1. (a) XRD-2DRSM for the Ge_{0.944}Sn_{0.036}C_{0.02}/Si sample. (b) Summary of the diffraction positions of Ge_{1-x-y}Sn_xC_y layers estimated with XRD-2DRSM.



Fig. 3. The area intensity of the peaks related to C-C and C-Sn/C-Ge bonds as a function of the Sn content for the $Ge_{1-x-y}Sn_xC_y/Si$ samples.



Fig. 5. Indirect Tauc plot obtained FT-IR absorption spectra for the $Ge_{1-x-y}Sn_xC_y/Si$ samples and Ge substrate.

References

(a)

ntensity (a. u.)

280

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Fig. 2. Photoelectron spectra of C1s bonding state for (a) $Ge_{0.98}C_{0.02}$ without Sn and (b) $Ge_{0.90}Sn_{0.08}C_{0.02}$ layers.



Raman-shift (cm⁻¹) Fig. 4. Raman scattering spectra related to (a) Ge-Ge and (b) Ge-C bonds for the $Ge_{1-x-y}Sn_xC_y/Si$ samples.



Fig. 6. The Sn content dependence of the energy bandgap for $Ge_{1-x-y}Sn_xC_y$ layers. Theoretically predicted energy bandgap of $Ge_{1-x}Sn_x$ without C is also shown for reference [2].